

Ongoing and planned RADFET developments

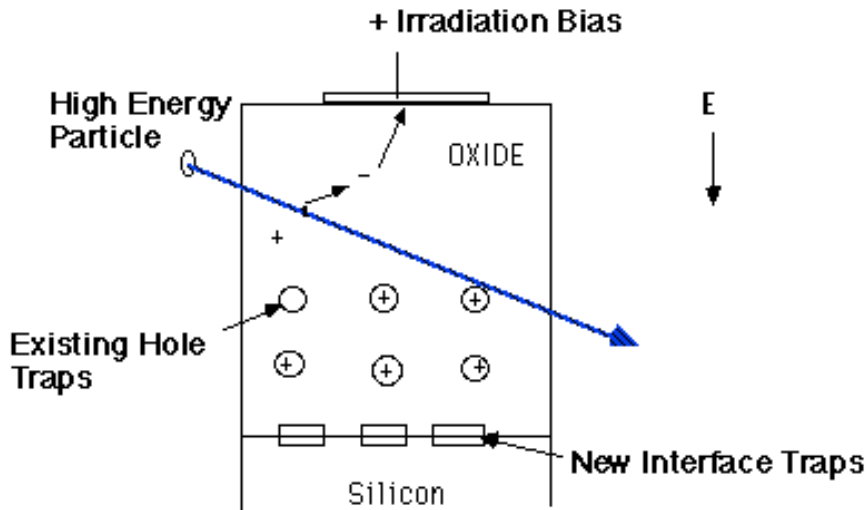
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Outline:

- What is RADFET and how does it work?
- Threshold implant optimisation
- Stacked RADFETs
- From space to terrestrial applications
- Success story: INVORAD

RADFET operating principle:



- Radiation creates electron-hole pairs
- Initial recombination of electrons and holes happens
- Non-recombined electrons leave the oxide; holes are trapped in the vicinity of the oxide/silicon interface
- RADFET threshold voltage (V_T) changes ($\Delta V_T \sim \text{Dose}$)

RADFET advantages over other dosimeters:

- Immediate read-out without destroying the data
- Extremely small sensor chip
- Very low or zero power consumption
- Technology suitable for connection to a microprocessor
- Comparatively low cost

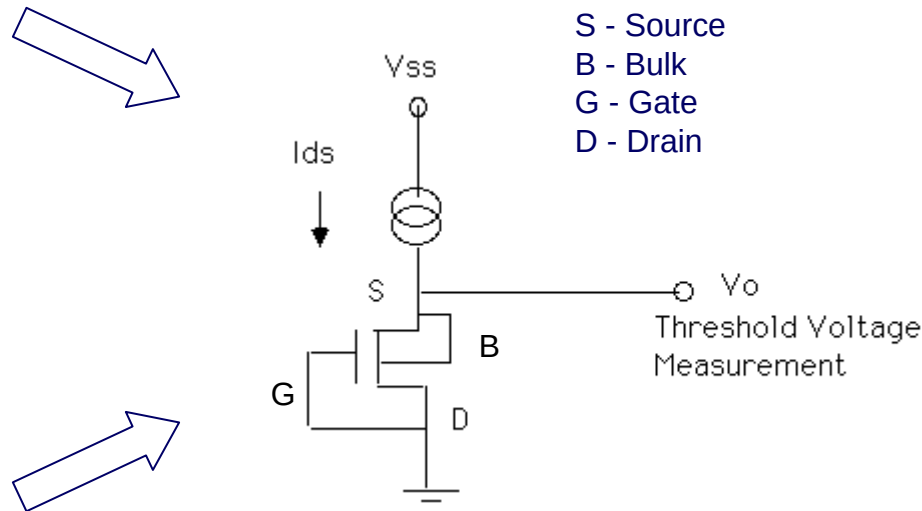
Applications:

- Nuclear industry and research
- Space dosimetry
- Radiotherapy
- Personal dosimetry [?]

RADFET biasing configurations:

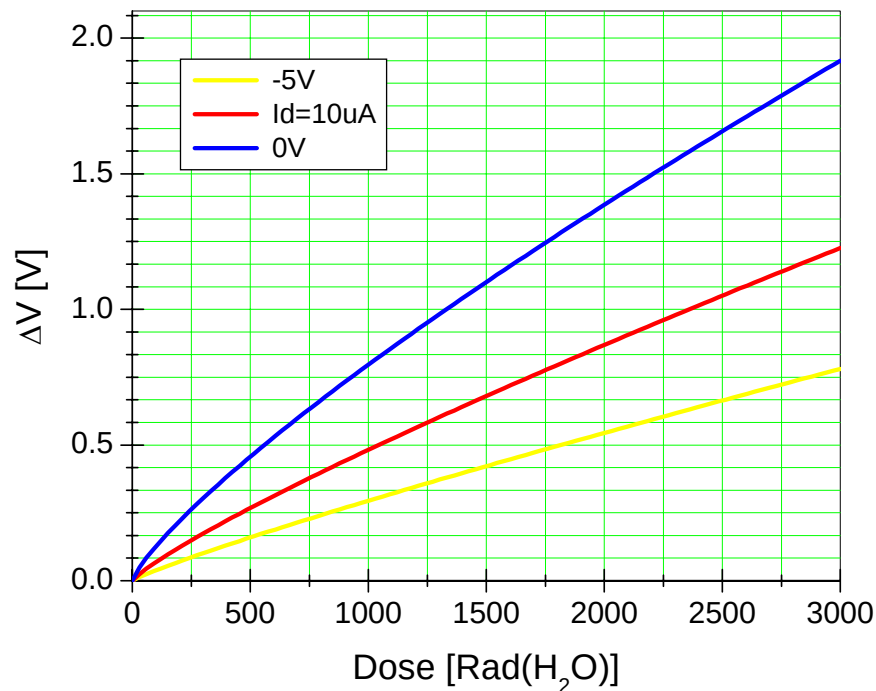
- Irradiation (sense mode): zero current; (B, S and D grounded); G can be:
 - Grounded ($V_{IRR}=V_{GS}=0V$)
 - Biased (typically $V_{IRR}=V_{GS}>0$)

Read-out mode: specified current ($I_{ds}=I_O$) applied to S=B; G=D grounded



- Irradiation (sense mode) and Read-out mode are the same

Co-60 calibration curves:



Calibration coefficients

The curve equation is of the form: $\Delta V = a \times \text{Dose}^b$; ΔV [Volts], Dose[Rad(H_2O)].

Bias	a	b	R-square	SSE
-5V	0.000643	0.8871	0.9999	0.00042
Cont $I_d=10\mu A$	0.001365	0.8494	0.9994	0.00475
0V	0.003166	0.8001	0.9976	0.04626

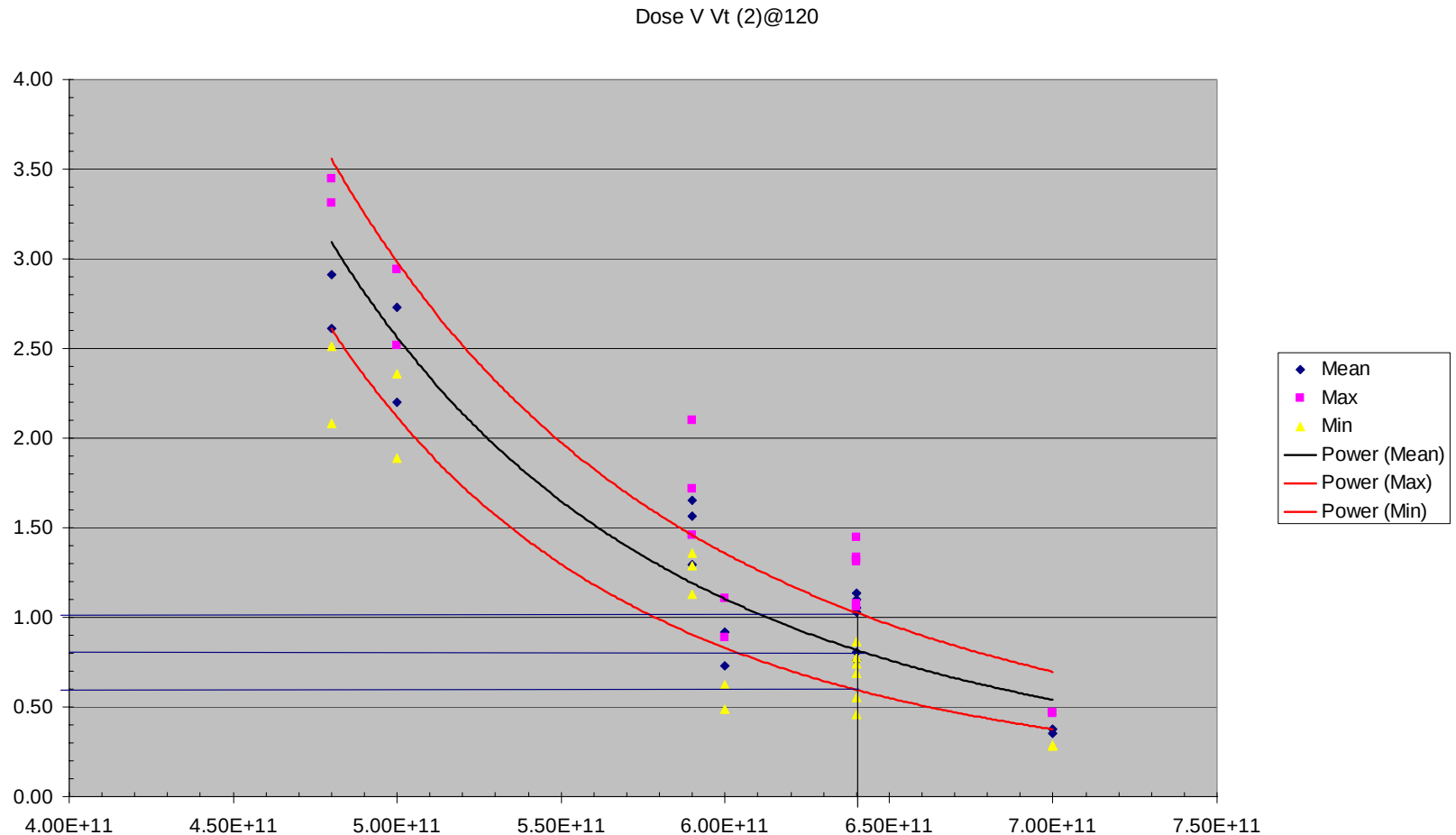
Preferred biasing configurations:

- Zero gate bias ($V_{\text{IRR}}=0\text{V}$)
 - ✓ Good sensitivity
 - ✓ Low fading
 - ✗ Need to switch between irradiation and read-out mode
- Continuous I_0
 - ✗ Somewhat decreased sensitivity
 - ✓ Low fading
 - ✓ No need for switching between irradiation and read-out mode

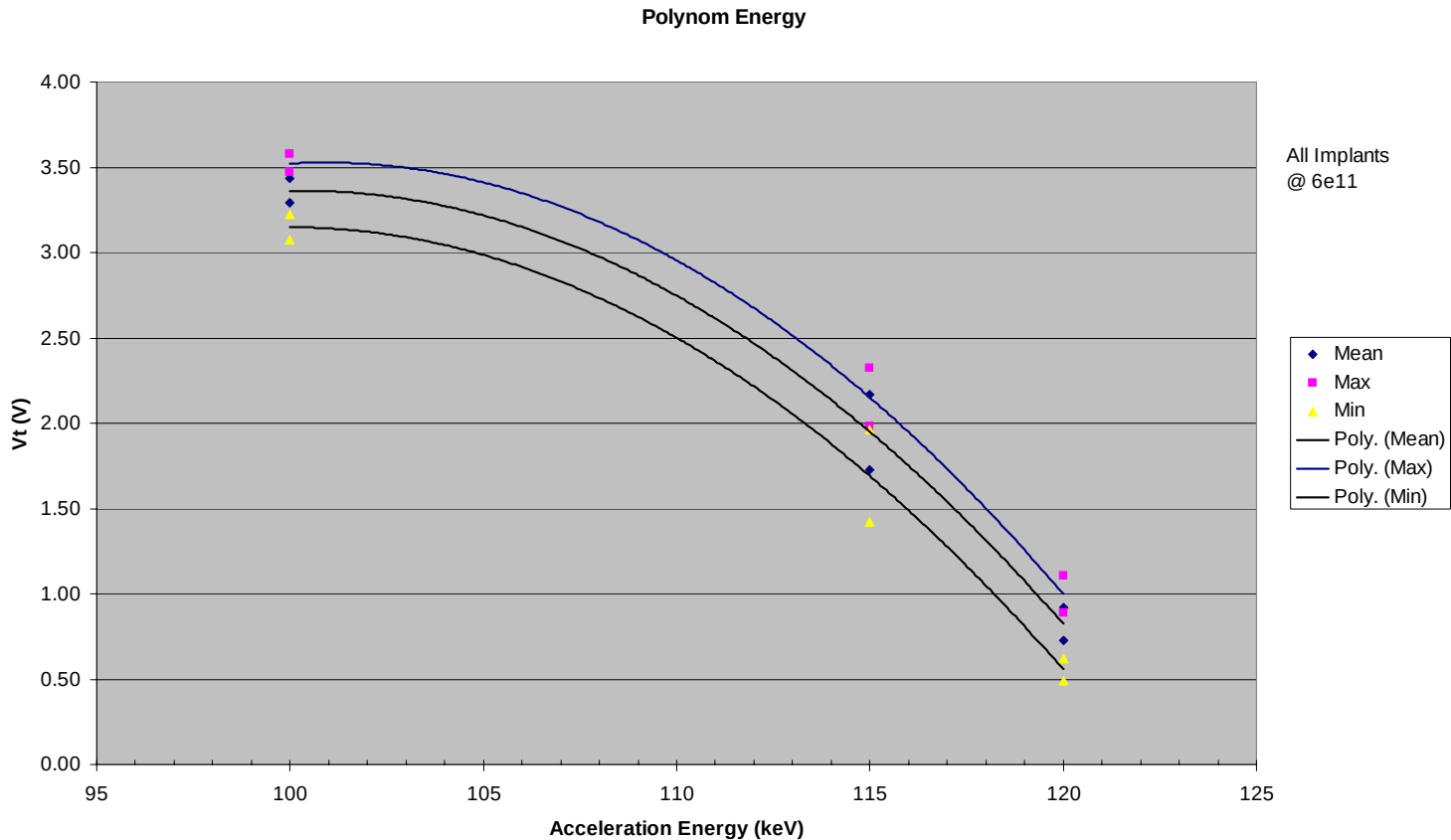
Threshold implant:

- “Native” V_{th} of 400nm oxide: $\sim 8V$
- Task: reduce V_{th} to $\sim 0.8V$ (1.5V)
- Benefits:
 - Higher voltage range
 - Increased sensitivity
- Implant optimisation:
 - Implant dose ($1/cm^2$)
 - Implant energy (keV)

Threshold implant optimisation (dose):



Threshold implant optimisation (energy):

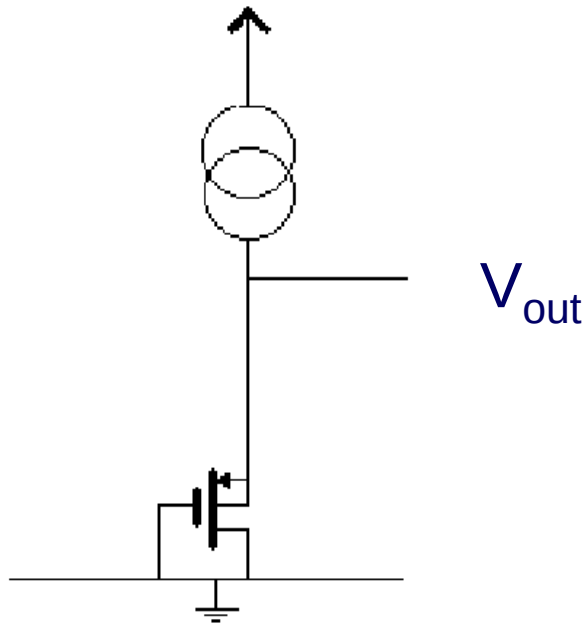


RADFET Reader Board System:

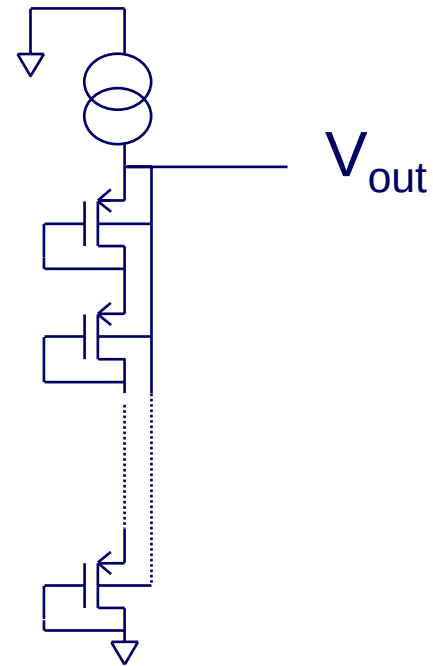


- Completely autonomous, easy to use system
- Reads up to 40 RADFETs in sequence
- Flexible RADFET biasing options
- Data saved in Excel files

Stacked RADFET:



Single



Stacked

From space to terrestrial applications:



OneDose (Sicel)



DVS (Sicel)

INVORAD project (www.invorad.com):



RADFET catheter line array



Delta⁴ (ScandiDos)